





SUBJECT AREAS:

PHOTOCHEMISTRY

CARBON NANOTUBES AND
FULLERENES

SURFACE CHEMISTRY

SPECTROSCOPY

Received 29 June 2012

Accepted 14 September 2012

Published 4 October 2012

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# Direct Optical Characterization of Graphene Growth and Domains on Growth Substrates

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We detailed a facile detection technique to optically characterize graphene growth and domains directly on growth substrates through a simple thermal annealing process. It was found that thermal annealing transformed the naked Cu to Cu oxides while keeping graphene and graphene-covered Cu intact. This increases the interference color contrast between Cu oxides and Cu, thus making graphene easily visible under an optical microscope. By using this simple method, we studied the factors that affect graphene nucleation and growth and achieved graphene domains with the domain size as large as  $\sim\!100~\mu m$ . The concept of chemically making graphene visible is universal, as demonstrated by the fact that a solution process based on selective  $H_2O_2$  oxidation has been developed to achieve the similar results in a shorter time. These techniques should be valuable for studies towards elucidating the parameters that control the grains, boundaries, structures and properties of graphene.

or large-area high-quality graphene growth, developing an effective detection technique for understanding the growth mechanisms is a prerequisite. In this study, we found a convenient optical method to directly characterize graphene domains and domain boundaries on growth substrates through selective oxidation for improving the growth conditions (Figure 1a). The unique features of graphene utilized here are its remarkable impermeability, thermal/chemical stability, and optical transparency in the visible region. Together with its other unusual electrical and mechanical properties, these properties have motivated intensive researches of graphene in physics, chemistry, and materials science in a short period<sup>1-5</sup>. In fact, graphene has been widely used as a key material in high-speed electronics<sup>6,7</sup>, flexible electronics<sup>5</sup> and optoelectronics<sup>8,9</sup> and holds the promise in future as a replacement material for silicon when silicon-based electronic technology reaches its quantum limits<sup>10</sup>. To this end, many synthetic methods have been developed and extensively explored in the past few years for meeting the great demand for large-area high-quality graphene, including the Scotch Tape peeling-off technique<sup>11</sup>, the hightemperature sublimation of SiC<sup>12</sup>, the intercalation of graphite<sup>13</sup>, the reduction from graphene oxides and derivatives<sup>3</sup>, the segregation from metal alloys<sup>14</sup>, and the metal-catalyzed chemical vapor deposition<sup>15</sup>. Of particular interest is the work by Li and colleagues<sup>4</sup>, where large-scale graphene with high quality were grown on copper foils through a surface adsorption-dominated chemical vapor deposition (CVD) process. Recently, by using the same method, micrometer-size individual single-crystal graphene domains with various shapes, such as hexagonal<sup>16-18</sup> and rectangular<sup>19,20</sup>, or large-area polycrystalline films<sup>4</sup> have been achieved. However, the characterization of these interesting domains need complex techniques, for example, SEM4,17, TEM21, STM22, LEEM23, AFM11, Raman24, and EBSD<sup>25,26</sup>. In some cases, only after transferred onto the SiO<sub>2</sub>/Si substrate with suitable thickness of a SiO<sub>2</sub> layer<sup>27</sup> or treated with nematic liquid crystals<sup>28</sup>, graphene domains could be observed by an optical method. It is the lack of a convenient detection technique for growth monitoring that hampers deeper understanding of the factors that control graphene growth, such as graphene nucleation, temperature, gas feeding rate, and pressure. The major advantage of the optical detection technique developed in the current study is its simplicity that allows holistic considerations of all the factors for optimizing growth conditions and thus controlling graphene quality.

### Results

Graphene visualization through selective oxidation. Graphene is transparent enough to allow the path of the visible light, which changes the interference color in contrast to the empty substrate. This can explain why



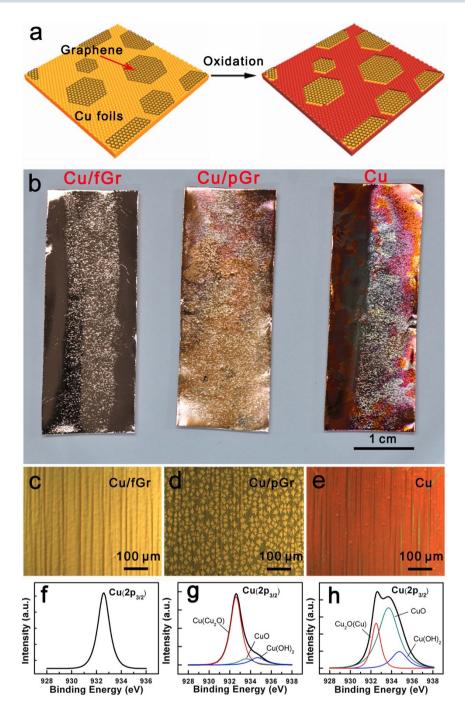


Figure 1 | Optical visualization of graphene directly on growth substrates. (a) A schematic illustration of how to optically characterize graphene domains directly on Cu foils through selective oxidation. (b) Photographs of Cu foils covered with fully grown graphene (Cu/fGr), with partially grown graphene (Cu/pGr) and without graphene after annealing in air  $(160^{\circ}\text{C}, 6 \text{ min})$ . (c–e) Optical microscopic images of Cu/fGr (c), Cu/pG (d), and Cu (e) foils after annealing. (f–h) XPS core-level Cu  $2p_{3/2}$  spectra of Cu/fGr (f), Cu/pG (g), and Cu (h) foils after annealing.

graphene, even for a single-layer graphene, can be visualized under an optical microscope by the naked eyes on silicon wafers with a certain thickness of  $\mathrm{SiO}_2$  but only after multistep chemical treatments and complex transfer processes from growth substrates such as Cu foils. The method we developed in this study is to optically detect graphene domains and domain boundaries directly on Cu foils through a simple selective annealing oxidation without further chemical treatments and transfer operations. The overall process for the selective annealing oxidation on Cu foils is shown in Fig. 1a. Because graphene has good thermal stability and impermeability<sup>29</sup>, under the proper annealing temperature (below  $400^{\circ}\mathrm{C}$ ) in air, graphene not only keep itself pristine without oxidation, but protects the surface of

Cu foils that is covered by graphene from oxidation. In contrast, due to the high chemical activity of Cu, the bare surface of Cu foils is oxidized to form Cu oxides, thus leading to significant changes in color. Therefore, the changes in color of Cu foils make graphene easily visible by the naked eyes using any common optical microscope as experimentally demonstrated below. For better comparison, the pure Cu foils without graphene (Cu), with partial graphene growth (Cu/pGr) and with full graphene growth (Cu/pGr) by a low pressure chemical vapor deposition (LPCVD) method at 1020°C were used. Before annealing, from both the photography images and optical microscopic images, all the samples looked similar (Supplementary Fig. S1). However, after annealing in air at 160°C



for 6 min, the Cu/fGr sample showed little color changes while the Cu/pGr sample changed to be brown madder and the pure Cu sample changed dramatically to be gray red in a large area (Fig. 1b). Consistently, in a small scale under an optical microscope, the Cu/fGr sample also looked the same as before annealing (Fig. 1c), but the pure Cu sample changes to be uniformly red (Fig. 1e). Remarkably, on the Cu/pGr sample, yellow graphene flakes with different shapes that were dispersed on the foliage green substrate was easily observed by the naked eyes directly on Cu foils (Fig. 1d).

Analysis of the oxidation mechanism. X-ray photoelectron spectroscopy (XPS) was used to analyze the surface compositions of the samples after annealing. The XPS spectrum of the Cu/fGr sample shows a single peak with binding energy at 932.6 eV (Fig. 2f), which corresponds to the Cu  $2p_{3/2}$  peak of Cu. For the Cu/pGr and Cu samples (Figs. 2g and 2h), the Cu  $2p_{3/2}$  spectra were fitted with several peaks after annealing, which correspond to the formation of different Cu oxides, Cu<sub>2</sub>O (932.5 eV), CuO (933.7 eV), and Cu(OH)<sub>2</sub> (934.7 eV)<sup>30,31</sup>. As the peaks for Cu (932.6 eV) and Cu<sub>2</sub>O (932.5 eV) are very close to each other, they are displayed as a single

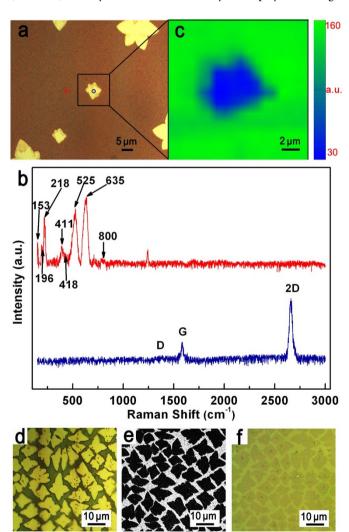


Figure 2 | Raman analysis after thermal annealing. (a) An optical micrograph of another Cu/pGr sample after annealing. (b) Raman spectra collected from the red- and blue-circled regions in (a), respectively. (c) A spatial Raman map of the intensity of the CuO band at 635 cm $^{-1}$  over the area with a black box (20  $\mu m \times 20~\mu m$ ) in (a). (d–e) Optical microscopic image and SEM image of the same Cu/pGr sample after annealing. (f) An optical micrograph of graphene films that have been transferred onto 300 nm SiO $_2$ /Si substrate.

peak here. We found that, in comparison with the Cu sample, the Cu/pGr sample showed a higher peak of Cu (Cu<sub>2</sub>O) and lower peaks of CuO and Cu(OH)<sub>2</sub>. In combination with the aforementioned single peak observation in the Cu/fGr sample, these differences prove the partial oxidation of Cu due to the protection of graphene on top of it.

To further demonstrate the oxidation mechanism, micro-Raman spectroscopy with 632.8 nm laser was used to study the surface property of an annealed Cu/pGr sample. In a blue-circled region, a small yellow graphene flake on the gray-red substrate was studied in detail (Fig. 2a). The Raman spectrum of the yellow region showed the distinct G ( $\sim$ 1580 cm<sup>-1</sup>) and 2D ( $\sim$ 2660 cm<sup>-1</sup>) peaks of graphene<sup>24</sup> with negligible peaks ascribed to Cu oxides and the D band of graphene (Fig. 2b). The intensity ratio of  $I_{2D}/I_G$  is about 2.9 and the half peak width of 2D peak is about 34 cm<sup>-1</sup>, which are characteristic of high-quality single-layer graphene<sup>24,32</sup>. These prove that the annealing process is nondestructive to graphene so that graphene remains pristine. In the control Raman spectrum from the gray-red substrate (red-circled), multiple peaks from 150 to 800 cm<sup>-1</sup> appeared, which correspond to various copper oxides—Cu<sub>2</sub>O (153, 196, 218, 525 cm<sup>-1</sup>), CuO (411, 635 cm<sup>-1</sup>) and Cu(OH)<sub>2</sub> (418, 800 cm<sup>-1</sup>) (Fig. 2b)<sup>30,33</sup>. This clearly demonstrates that Cu surfaces in the regions without graphene protection were oxidized during annealing. To probe the consistency, we screened the spatial map of the intensity of the CuO band at 635 cm<sup>-1</sup> over the area with a black box (20  $\mu$ m  $\times$  20  $\mu$ m, Fig. 2a). As shown in Fig. 2c, the Raman map does not indicate obvious peaks of the 635 cm<sup>-1</sup> (CuO) band in the region under graphene, demonstrating that Cu in this region was intact after thermal treatment, and the unoxidized Cu region has the same profile as graphene. Therefore, we conclude that, due to the oxidation happening on Cu surfaces without graphene protection to form Cu oxides accompanied by significant changes in color, graphene becomes optically visible directly on the growth substrate.

To prove the reliability of the detection technique, we used both scanning electron microscopic (SEM) and optical methods to compare graphene morphologies on Cu substrates or SiO<sub>2</sub>/Si substrates after graphene transfer, respectively<sup>4,14,20,34</sup>. As shown in Figs. 2d–f, the optical image obtained by our annealing method on Cu foils displays almost the same graphene morphologies as those observed by SEM on the same sample or by the optical method on SiO<sub>2</sub>/Si substrates after graphene transfer. In addition, the SEM images from the same Cu/pGr sample before and after annealing and optical micrographs of transferred graphene on SiO<sub>2</sub>/Si substrate are nearly identical to each other (Supplementary Fig. S2). These results consistently prove that our method is as reliable as traditional SEM and optical methods, but much more efficient due to its simplicity without complex transfer processes and the dependence on expensive equipments, therefore setting the foundation of the following studies.

### Discussion

After having established this convenient method, we then turned our attention to exploring the effects of the factors, such as methane feeding rate  $(J_{Me})$  or partial pressures  $(P_{Me})$ , temperature (T), and substrate surface imperfection, on graphene growth. Firstly, by keeping the constant growth temperature at 1000  $^{\circ}$ C, we only changed  $J_{\text{Me}}$ from 1.0 sccm with  $P_{\rm Me}$  of 45 mTorr to 0.3 sccm with  $P_{\rm Me}$  of 15 mTorr for graphene growth for 1.5 min. We found that the densities of graphene domains only showed a slight decrease as demonstrated in Figs. 3a and 3b. In contrast, when the growth temperature changed from 1000°C to 1020°C at constant gas feeding rate of 0.3 sccm with  $P_{\rm Me}$  of 15 mTorr for graphene growth for 1.5 min, the densities of graphene domains decreased significantly but with the obvious increase of the domain size (Figs. 3b and 3c). It was reported that suppressing the nucleation density of the substrates is important for growing graphene with large-size domain and high quality<sup>16,17,20</sup>. High growth temperature is helpful to reduce volatile impurities, contaminants, and defects on the copper surface and



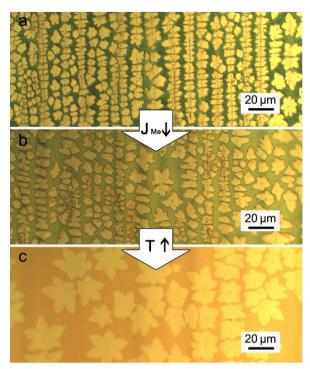
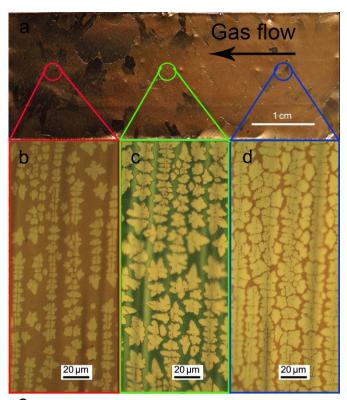


Figure 3 | Effects of temperature and gas feeding rate on graphene growth. Optical micrographs of Cu foils under different growth conditions after annealing: T (°C)/ $J_{\rm Me}$  (sccm) for 1.5 min: (a) 1000/1.0, (b) 1000/0.3, (c) 1020/0.3.

improve the surface flatness, thus resulting in the suppression of graphene nucleation. Therefore, the phenomena observed above in the current case can be explained as follows: Due to the reduction of graphene nucleation at higher temperature, each graphene domain tends to grow faster and larger when the gas feeding rate keeps constant. With the same density of graphene nucleation at the same temperature, it is reasonable that we did not observe the obvious differences in graphene growth when the gas feeding rates exceed the graphene growth rate. Consequently, it is clear that substrate surface imperfection (or temperature) considerably has more effect on graphene nucleation and growth kinetics, thus controlling graphene growth quality. This conclusion can be further corroborated by the following experiments.

To further investigate the effect of the gas feeding rate on graphene growth, another series of interesting experiments we performed are to study graphene growth at different positions on a large Cu foil. In this case, a 2 cm × 6 cm Cu foil was used for graphene growth under 1000°C/1 sccm CH<sub>4</sub> for 1.5 min. After annealing treatment, obvious decreases in the size of graphene domains at the different positions of the same Cu foil along the forward direction of gas flow were observed (Figs. 4a-d). However, when we put the small pieces of different Cu foils at the similar positions used above along the direction of gas flow but without any other Cu foils ahead for graphene growth under the same condition (Supplementary Fig. S3), we found that the domain sizes in all the samples were nearly identical. We hypothesize that the possible reason for such an uneven growth on large Cu foils is that, as illustrated in Fig. 4e, with the depletion of gas carbon source (CH<sub>4</sub>) the depletion thickness for CH<sub>4</sub> mass transport to the Cu surface increases but the surface CH<sub>4</sub> concentration decreases along the gas flow direction. As the growth rate for graphene domain is proportional to the surface carbon source concentration<sup>21</sup>, it is not surprising that with the decrease of surface CH<sub>4</sub> concentration the graphene domain sizes decrease along the direction of gas flow. Note that the densities of graphene nucleation at the different positions of the same Cu foils are close since the



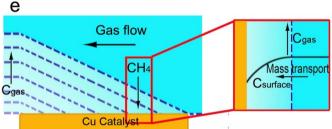


Figure 4 | Position effect on graphene growth. (a) Photograph of a large Cu foil after graphene growth under  $1000^{\circ}C/1$  sccm CH<sub>4</sub> for 1.5 min and further annealing. (b–d) Optical micrographs of graphene observed at different spots along the gas flow direction. (e) A schematic diagram for the gas carbon source distribution during the growth.

temperature is the same (Supplementary Figs. S3–S4), which is consistent with the results discussed above.

Since our detection technique is developed directly on Cu substrates, graphene domains observed optically also reflect the surface properties of Cu substrates, thus in turn allowing us to study the effects of the morphology and impurity of Cu substrates on graphene growth. In most cases, parallel nucleation seeds along the waveshaped grains of Cu foils were observed (Fig. 3 and Supplementary Fig. S5). At higher growth temperature, the surface flatness and surface imperfection of the Cu substrate (as discussed above) are improved, and thus the nucleation density of seeds along the grains decreases (Fig. 3c). In the case of graphene growth on the inside of the Cu enclosure<sup>16</sup>, the number of nucleation seeds at the grains can be decreased because of the decrease of the concentration of the active gas (Supplementary Fig. S5). In both cases, graphene with large domains was obtained<sup>35-38</sup>. Therefore, decreasing defect sites on polycrystalline copper foils could afford high-quality graphene with large domain. In order to decrease the defects of the Cu surface, Cu foils were pretreated by acetic acid for 5 min, and then washed with copious ultrapure water and ethanol. After acid pretreatment, the possible impurities and defects potentially as graphene nucleation sites were mostly removed. In comparison with Cu foils

without any pretreatment, the density of graphene domains on Cu foils with acid pretreatment dramatically decreased from 800 ea/  $\rm mm^2$  (the number of domains per square micrometer) down to 40 ea/mm² under  $1020^{\circ}\rm{C}/0.3$  sccm  $\rm{CH_4}$  for 1 min (Supplementary Fig. S6). Oxygen plasma was also used to remove the surface contaminants³9, however, it turned out to be that the pretreatment of oxygen plasma had no significant effect on the density of graphene nucleation (Supplementary Fig. S7). The reason for the nucleation decrease by acid pretreatment could be that with the aid of  $\rm{O_2}$  in air, acetic acid etched the active defect sites and thus decrease the nucleation sites (Supplementary Fig. S6)⁴0. Note that long-time acid pretreatment could overetch Cu foils and introduce new surface roughness, potentially increasing the graphene nucleation sites.

On the basis of deeper understanding of the interplay between the Cu surface and graphene growth, we are able to perform the holistic consideration for optimizing growth conditions. With high growth temperature and low methane flow rate, Cu substrates after proper acid pretreatment were used to grow high-quality graphene. With the growth time increase, larger and larger graphene domains were gradually obtained (Figs. 5a–c). As shown in Fig. 5d, graphene domains with the domain size as large as  $\sim\!100~\mu{\rm m}$  are achieved, much larger than the case reported previously under the similar growth conditions  $^{20}$ .

Finally, it was found that the chemical concept of optical visualization of graphene domains directly on Cu substrates is universal and can be extended to other chemical reactions. In general, chemical reactions can transform Cu to its derivatives and correspondingly produce the interference color contrast between the naked Cu surface and that protected by graphene, thus making graphene optically visible. Previous reports demonstrated that sulfur and H<sub>2</sub>O<sub>2</sub> could effectively react with Cu to form insoluble Cu compounds<sup>30,41</sup>. We then used sulfur in ethanol and H2O2 in water to possibly detect graphene growth through a solution process instead of thermal annealing. After immerging Cu foils into the saturated ethanol solution of sulfur for ~30 s, bright yellow graphene was developed from the black green substrate of copper sulfide (Supplementary Fig. S8b)41. However, due to the high reactivity of sulfur with Cu, sulfur can penetrate the graphene sheet through the edges<sup>42</sup> and make graphene domains fuzzy. Remarkably, after development in 15%  $H_2O_2$  aqueous solution for  $\sim 30$  s, we achieved optical micrographs with clear graphene profiles that are as good as those obtained by annealing (Supplementary Figs. S8a and S8c). Therefore, H<sub>2</sub>O<sub>2</sub> is a good reagent to quickly characterize graphene domains and boundaries directly on Cu substrates through a solution method.

Taken together this study described our finding of a convenient detection technique for optically visualizing graphene domains and domain boundaries directly on growth substrates through either thermal annealing or solution treatment. Both thermal annealing and chemical treatment initiate the oxidation of the naked Cu to form Cu oxides accompanied by the interference color change, thus differentiating graphene from the substrate. By taking advantage of this method, we demonstrated the holistic consideration of the factors that control graphene nucleation and growth kinetics, such as growth temperature, gas feeding rate and substrate surface morphology, to realize individual high-quality graphene with the domain size as large as  $\sim$ 100 µm, paving the way toward controllable synthesis of single-crystal graphene and large-scale fabrication of singlecrystalline defect-free graphene devices. Due to its simplicity, therefore, this nondestructive technique should open a universal and useful avenue for studying the intrinsic mechanism of graphene growth to elucidate the interplay among the parameters that control the grains, boundaries, structures and properties of graphene.

## **Methods**

**Copper substrate pretreatment.** The pretreatment of copper foils is as follows: the copper foil was immerged into glacial acetic acid for 5 min, rinsed by copious ultrapure water and ethanol for several times, and air-dried in a clean glass petri dish.

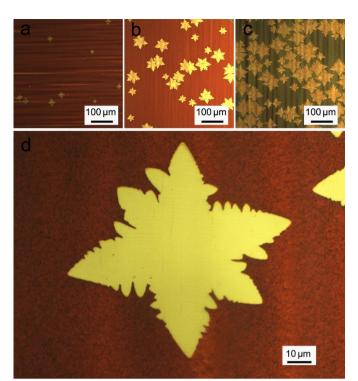


Figure 5 | Holistic optimization of growth conditions. Optical micrographs of acid-pretreated Cu foils under  $1020^{\circ}$ C/0.3 sccm CH<sub>4</sub> at the different growth time: (a) 1 min, (b) 3 min, (c) 6 min. (d) The enlarged optical micrograph of a typical graphene domain.

Graphene growth. A split tube furnace with 1-inch quartz tube was used for graphene growth on 25  $\mu m$  thick copper foil (99.8% Alfa Aesar #13382) by a low pressure chemical vapor deposition (LPCVD) method\*. During the growth, copper foil was first annealed at a desired growth temperature for 30 min under 10 sccm  $H_2$  with a pressure of 450 mTorr; then,  $H_2$  was changed to 2 sccm with a pressure of 95 mTorr and a certain amount of  $CH_4$  was introduced to the furnace for graphene growth with a proper time; finally, the furnace quickly cooled down to the room temperature under a 10 sccm  $H_2$  gas flow. The control pure Cu foil without graphene growth also underwent the same process but without  $CH_4$  during treatments.

**Thermal annealing and solution treatment.** The development of graphene on Cu foils was carried out by heating the samples in air atmosphere on hot plate (IKA® C-MAG HP7) at temperature of  $160^\circ\text{C}$  for 6 min. For the development of graphene by a solution method, the samples were immerged into the saturated solution of sulfur in ethanol or the  $15\text{M}_2\text{O}_2$  aqueous solution for 30 s, rinsed by ultrapure water and dried by a nitrogen gas.

Characterization equipments. Optical microscopic images were obtained with a Nikon Eclipse LV100 POL Microscope. X-ray photoelectron spectroscopic (XPS) data were acquired from an ESCALab220i-XL electron spectrometer with a 300 W AlK $\alpha$  radiation. Binding energies were referenced to the C 1s binding energy at 284.5 eV. SEM image was taken with S-4800 UHR FE-SEM using a voltage of 1 KV. Raman spectra were collected using a micro-Raman spectroscope (Renishaw 1000), with an excitation wavelength of 632.8 nm.

Graphene transfer. Transferring graphene to 300 nm SiO<sub>2</sub>/Si wafer substrates was carried out as reported previously<sup>34</sup>. First, a layer of poly (methyl methacrylate) (PMMA) (MicroChem 495 PMMA A6) was spin-cast on Cu foils after graphene growth at 3000 rpm for 30 second and baked at 180°C for 2 min. Second, oxygen plasma was used to remove graphene on the back side of Cu foils. Next, copper was wet-etched in an aqueous solution of (NH<sub>4</sub>)<sub>2</sub>S<sub>2</sub>O<sub>8</sub> for about 8 hours, resulting in graphene/PMMA films floating in the etchant. Then, the films were rinsed in ultrapure water for three times, transferred to 300 nm SiO<sub>2</sub>/Si substrates and baked at 50°C for half an hour. Finally, PMMA was removed by annealing the samples at 420°C for 180 min under hydrogen (600 sccm) and argon (300 sccm) gas flow.

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## **Acknowledgements**

We acknowledge primary financial support from MOST (2009CB623703 and 2012CB921404), NSFC (20833001, 51121091, 2112016, and 21003002), FANEDD (2007B21), 111 Project (B08001), and BSTSP (2009A01).

### **Author contributions**

C. J., J. J., S. L. and L. G. performed the experiments. C. J. and X. G. designed research and wrote the manuscript. All authors discussed the results and commented on the manuscript.

## **Additional information**

 ${\bf Supplementary\ information\ accompanies\ this\ paper\ at\ http://www.nature.com/scientific$ reports

Competing financial interests: The authors declare no competing financial interests.

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How to cite this article: Jia, C., Jiang, J., Gan, L. & Guo, X. Direct Optical Characterization of Graphene Growth and Domains on Growth Substrates. *Sci. Rep.* 2, 707; DOI:10.1038/srep00707 (2012).